VE320 Intro to Semiconductor Devices Summer 2022 — Problem Set 2

JOINT INSTITUTE 交大窓面根学院

May 27, 2022

Exercise 2.1

Two possible valence bands are shown in the E versus k diagram given in Figure 1. State which band will result in the heavier hole effective mass; state why.

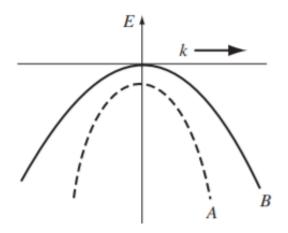


Figure 1: Valence bands for Problem 2.1.

- (a) The forbidden bandgap energy in GaAs is 1.42eV. (i) Determine the minimum frequency of an incident photon that can interact with a valence electron and elevate the electron to the conduction band. (ii) What is the corresponding wavelength?
 - (b) Repeat part (a) for silicon with a bandgap energy of 1.12eV.

The energy-band diagram for silicon is shown in Figure 2. The minimum energy in the conduction band is in the [100] direction. The energy in this one-dimensional direction near the minimum value can be approximated by

$$E = E_0 - E_1 \cos \alpha \left(k - k_0 \right)$$

where k_0 is the value of k at the minimum energy. Determine the effective mass of the particle at $k = k_0$ in terms of the equation parameters.

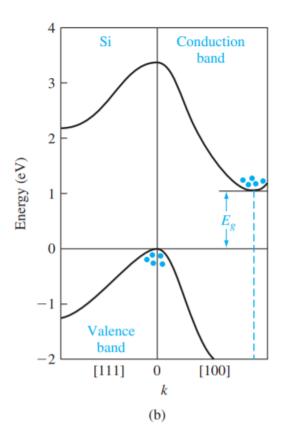


Figure 2: Energy-band structures of Si

- (a) Determine the total number (#/cm³) of energy states in silicon between E_v and E_v-3kT at (i) T=300 K and (ii) T=400 K.
 - (b) Repeat part (a) for GaAs.

Exercise 2.5

- (a) For silicon, find the ratio of the density of states in the conduction band at $E = E_c + kT$ to the density of states in the valence band at $E = E_v kT$.
 - (b) Repeat part (a) for GaAs.

Consider the energy levels shown in Figure 3. Let $T=300~\mathrm{K}$.

- (a) If $E_1 E_F = 0.30 \text{eV}$, determine the probability that an energy state at $E = E_1$ is occupied by an electron and the probability that an energy state at $E = E_2$ is empty.
 - (b) Repeat part (a) if $E_F E_2 = 0.40 \text{eV}$.

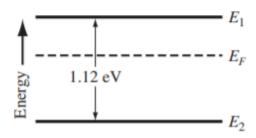


Figure 3: Energy levels for Problem 2.6

- (a) The carrier effective masses in a semiconductor are $m_n^* = 1.21m_0$ and $m_p^* = 0.70m_0$. Determine the position of the intrinsic Fermi level with respect to the center of the bandgap at T = 300 K.
 - (b) Repeat part (a) if $m_n^* = 0.080m_0$ and $m_p^* = 0.75m_0$.

Exercise 2.8

Silicon at T=300 K is doped with boron atoms such that the concentration of holes is $p_0=5\times 10^{15}$ cm⁻³.

- (a) Find $E_F E_v$.
- (b) Determine $E_c E_F$.
- (c) Determine n_0 .
- (d) Which carrier is the majority carrier?
- (e) Determine $E_{Fi} E_F$.

Reference

1. Neamen, Donald A. Semiconductor physics and devices: basic principles. McGrawhill, 2003.